

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	0	(etch\$4 adj surface same protect\$4 adj film same ammonium adj fluoride same thickness same "500" adj nm same supply adj port same energy adj generating adj element same opening adj patterns)	US-PGPUB; USPAT	OR	OFF	2007/08/23 09:02
S1	10852	(ink adj jet adj record\$4)	US-PGPUB; USPAT	OR	OFF	2006/03/30 13:56
S2	1867	(S1 and head near5 substrate\$4)	US-PGPUB; USPAT	OR	OFF	2006/03/29 13:54
S3	73	S2 and (ink adj supply adj hole\$4)	US-PGPUB; USPAT	OR	OFF	2006/03/29 13:55
S4	29	S3 and (protect\$4 near5 film\$4)	US-PGPUB; USPAT	OR	OFF	2006/03/29 13:56
S5	25	S4 and etch\$4	US-PGPUB; USPAT	OR	OFF	2006/03/29 13:56
S6	9	S5 and (openin\$4 near5 pattern\$4)	US-PGPUB; USPAT	OR	OFF	2006/03/29 14:11
S7	21	S5 and (an\$1isotrop\$4 adj etch\$4)	US-PGPUB; USPAT	OR	OFF	2006/03/29 13:58
S8	21	S7 and (silicon or Si)	US-PGPUB; USPAT	OR	OFF	2006/03/29 13:58
S9	13	S8 and ((silicon adj oxide) or SiO)	US-PGPUB; USPAT	OR	OFF	2006/03/29 14:11
S10	2	S9 and (poly\$1etheramide)	US-PGPUB; USPAT	OR	OFF	2006/03/29 15:12
S11	0	S8 and ((silicon adj oxide) or SiO)	EPO; JPO; DERWENT	OR	OFF	2006/03/29 14:11
S12	3	S9 and (polyether adj amide)	US-PGPUB; USPAT	OR	OFF	2006/03/29 15:17
S13	1	("6708398").PN.	US-PGPUB; USPAT	OR	OFF	2006/03/29 15:18
S14	5	((("5478606") or ("6126271") or ("6245245") or ("6390606") or ("6467884"))).PN.	US-PGPUB; USPAT	OR	OFF	2006/03/30 08:52
S15	10870	(ink adj jet adj record\$4)	US-PGPUB; USPAT	OR	OFF	2006/03/30 08:51
S16	1874	(S15 and head near5 substrate\$4)	US-PGPUB; USPAT	OR	OFF	2006/03/30 08:51
S17	75	S16 and (ink adj supply adj hole\$4)	US-PGPUB; USPAT	OR	OFF	2006/03/30 08:51
S18	29	S17 and (protect\$4 near5 film\$4)	US-PGPUB; USPAT	OR	OFF	2006/03/30 08:51

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S19	25	S18 and etch\$4	US-PGPUB; USPAT	OR	OFF	2006/03/30 08:51
S20	21	S19 and (an\$1isotrop\$4 adj etch\$4)	US-PGPUB; USPAT	OR	OFF	2006/03/30 08:51
S21	21	S20 and (silicon or Si)	US-PGPUB; USPAT	OR	OFF	2006/03/30 08:51
S22	0	S14 and S21	US-PGPUB; USPAT	OR	OFF	2006/03/30 08:52
S23	0	S14 and S20	US-PGPUB; USPAT	OR	OFF	2006/03/30 08:52
S24	6522	216/27,37,41;438/689,700,702,719, 723.ccls.	US-PGPUB; USPAT	OR	OFF	2006/03/30 13:57
S25	10870	(ink adj jet adj record\$4)	US-PGPUB; USPAT	OR	OFF	2006/03/30 13:58
S26	1874	(S25 and head near5 substrate\$4)	US-PGPUB; USPAT	OR	OFF	2006/03/30 13:58
S27	75	S26 and (ink adj supply adj hole\$4)	US-PGPUB; USPAT	OR	OFF	2006/03/30 13:58
S28	29	S27 and (protect\$4 near5 film\$4)	US-PGPUB; USPAT	OR	OFF	2006/03/30 13:58
S29	25	S28 and etch\$4	US-PGPUB; USPAT	OR	OFF	2006/03/30 13:58
S30	21	S29 and (an\$1isotrop\$4 adj etch\$4)	US-PGPUB; USPAT	OR	OFF	2006/03/30 13:58
S31	21	S30 and (silicon or Si)	US-PGPUB; USPAT	OR	OFF	2006/03/30 13:58
S32	13	S31 and ((silicon adj oxide) or SiO)	US-PGPUB; USPAT	OR	OFF	2006/03/30 13:58
S33	4	S24 and S32	US-PGPUB; USPAT	OR	OFF	2006/03/30 13:58